

~~4/21/03~~
~~JE~~
~~REB~~
Informal
not for Entry
gr 4/21/03

PATENT
P56342

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

DEOK-HYEON CHOE *et al.*

Serial No.: 09/836,550

Examiner: PHINNEY, JASON

Filed: 18 April 2001

Art Unit: 2879

For: TENSION MASK FOR COLOR CRT, METHOD FOR MANUFACTURING THE
TENSION MASK, AND EXPOSURE MASK USED IN THE MANUFACTURE
OF THE TENSION MASK

CERTIFICATE OF FACSIMILE TRANSMISSION

Assistant Commissioner
for Patents

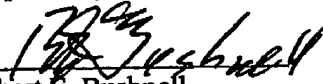
Washington, D.C. 20231

Attn: **Mr. Jason PHINNEY**Facsimile No.: **(703)746-9405**

Sir:

This is to certify that on this, the 21st of April 2003, this Response to Requirement for Restriction, was facsimile transmitted to the U.S. Patent & Trademark Office. A duplicate copy of the Response is concurrently being filed in the Office.

Respectfully submitted,



Robert E. Bushnell,
Attorney for the Applicant
Registration No.: 27,774

Suite 300, 1522 "K" Street, N.W.
Washington, D.C. 20005
Phone: (202) 408-9040
Fax: (202) 289-7100

Folio: P56342
Date: 21 April 2003
I.D.: REB/sb

PATENT
P56342**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of:

DEOK-HYEON CHOIE et al.

Serial No.: 09/836,550

Examiner: PHINNEY, JASON

Filed: 18 April 2001

Art Unit: 2879

For: TENSION MASK FOR COLOR CRT, METHOD FOR MANUFACTURING THE
TENSION MASK, AND EXPOSURE MASK USED IN THE MANUFACTURE
OF THE TENSION MASK

RESPONSE TO REQUIREMENT FOR RESTRICTION

Assistant Commissioner
for Patents
Washington, D.C. 20231

Sir:

In response to the telephone requirement for restriction by the Examiner on 14 April 2003,
entry of the following response and remarks, prior to examination for the above-captioned
application, is respectfully requested.

Folio: P56342
Date: 4/21/03
I.D.: REB/SS/sb